	Application No.	Applicant(s)
Notice of Allowability	10/775,012 Examiner	DALY ET AL.  Art Unit
rouse of Amorrasmy	, cxammer	Artonic
	Hau H. Nguyen	2628
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not included will be mailed in due course. THIS
1. This communication is responsive to <u>1/89/2006</u> .		
2. The allowed claim(s) is/are <u>1-3</u> .		
<ul> <li>3. ☐ Acknowledgment is made of a claim for foreign priority unally a) ☐ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☐ Certified copies of the priority documents have</li> </ul>		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1) 🔲 hereto or 2) 🔲 to Paper No./Mail Date		
(b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s)	E □ Nation of Informal P	otant Application (PTO 152)
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Dotice of Draftperson's Patent Drawing Review (PTO-948)</li> </ol>	6. ☐ Interview Summary	atent Application (PTO-152) (PTO-413)
	Paper No./Mail Dat	te .
<ol> <li>Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date</li> </ol>	8), 7. Examiner's Amend	nenvComment
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛭 Examiner's Stateme	ent of Reasons for Allowance
of Biological Material	9. 🗌 Other	1/2
	ī	Kee M. Tung

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05) Application/Control Number: 10/775,012

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## Allowable Subject Matter

1. Claims 1-3 are allowed.

## Reasons for Allowance

2. The following is an examiner's statement of reasons for allowance:

The prior art taken singly or in combination does not teach or suggest, method for creating an image dither pattern structure, among other things, comprising:

establishing a first multi-dimensional array of image dither pattern tiles, said array comprising a first upper horizontal spatial frequency bound, a first lower horizontal spatial frequency bound, a first upper vertical spatial frequency bound, a first lower vertical spatial frequency bound, a first upper temporal frequency bound and a first lower temporal frequency bound; wherein said spatial frequency bounds and said temporal frequency bounds define a high-pass pattern configuration;

establishing a second multi-dimensional array of image dither pattern tiles, said array comprising a second upper horizontal spatial frequency bound, a second lower horizontal spatial frequency bound, a second upper vertical spatial frequency bound, a second lower vertical spatial frequency bound, a second upper temporal frequency bound and a second lower temporal frequency bound; wherein said second lower temporal frequency bound is lower than said first lower temporal frequency bound.

The references to Spaulding et al. (U.S. Patent No. 6,091,849) and Doherty et al. (U.S. Patent No. 6,795,085) are made of records as disclosing related creating dither pattern structure.

The closest prior art, Spaulding et al. teaches a method of providing a matrix of dither values for each color channel of the digital color image wherein two or more of the matrices of

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dither values are designed jointly to minimize a visual cost function utilizing spatial frequencies; associated a first dither matrix with a first range of image characteristic values; and associated a second dither matrix with a second range of image characteristic values. Doherty et al. teach a dithering method of reducing contour by generating dither array utilizing both spatial and temporal frequencies.

However, references Spaulding et al. and Doherty et al. neither teach the frequency bounds nor define the high-pass pattern configuration as specified in the claims.

## Conclusion

- 3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."
- 4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hau H. Nguyen whose telephone number is: 571-272-7787. The examiner can normally be reached on MON-FRI from 8:30-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kee Tung can be reached on (571) 272-7794.

The fax number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system contact the Electronic Business Center (EBC) at 866-2 17-9197 (toll-free).

H. Nguyen

4/13/2006

Kee M. Tung Primary Examiner